

<b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>				Docket Number		Application Number	
				M4065.0223/P223		09/517,314	
				Applicant(s)			
				Chih-chen Cho			
				Filing Date		Group Art Unit	
				March 2, 2000		2811	
<b>U.S. PATENT DOCUMENTS</b>							
*EXAMINER INITIAL	REF	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
<i>PHL</i>	A	5,122,476	6/16/92	Fazan, et al.			
<i>PHL</i>	B	5,097,381	3/17/92	Vo			
<i>PHL</i>	C	5,880,030	3/9/99	Fang, et al.			
<b>FOREIGN PATENT DOCUMENTS</b>							
	REF	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translations YES NO
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
<i>PHL</i>		Peter Singer, "Dual-Damascene Challenges Dielectric Etch", Semiconductor International, August 1999, pgs. 68-72.					

EXAMINER	DATE CONSIDERED
Not Yet Assigned	<i>Donghee Kang</i> <i>1-16-01</i>
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.	

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